

Effect of solidification cooling rate and phosphorus inoculation on number per unit volume of primary silicon particles in hypereutectic aluminium–silicon alloys

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Published online: 5 October 2005

Collected data on derived number per unit volume \bar{N}_V of primary silicon particles in hypereutectic Al-Si alloys show a power relationship with solidification cooling rate \dot{T} of the form $\bar{N}_V = A\dot{T}^n$ where typically $n \sim 1$ and $A \simeq 130 \text{ mm}^{-3} (\text{K/s})^{-1}$ in the absence of phosphorus and $A \simeq 720 \text{ mm}^{-3} (\text{K/s})^{-1}$ in its presence. Significantly lower apparent values of \bar{N}_V from one set of results appear to stem from measurement of a mean long dimension rather than diameter of particle sections as well as lower measured undercoolings than in Bridgman experiments at similar \dot{T} . © 2005 Springer Science + Business Media, Inc.

Size refinement of primary silicon in hypereutectic Al-Si base alloys is a key requirement for meeting property targets [1–4] and can be achieved by inoculation with phosphorus, as is routinely applied in conventional foundry practice [5], or by increasing the cooling rate during solidification, which has been applied, for example, in the development of improved performance in alloys processed by spray forming [6], and other rapid solidification technologies [8]. Arnold and Prestley [9] showed micrographs indicating size refinement of primary silicon in Al-16 wt%Si with increase of solidification cooling rate \dot{T} in the range 0.6 to 1.5 K/s, but the results were not quantified. Sulzer [10] reported refinement of primary silicon size from $27 \pm 4 \mu\text{m}$ at 3 K/s to $15.5 \pm 1.5 \mu\text{m}$ at 70 K/s for Al-20Si-1Cu-1Mg (wt%) base alloy with 0.16 wt% P addition. Kaneko *et al.* [11] determined average size and number per unit area of section \bar{N}_A of primary silicon in Al-19 wt%Si-0.02 wt%P alloy over the range of \dot{T} between 0.02 and 2 K/s, and obtained a linear relationship between logarithm of derived number of particles per unit volume \bar{N}_V and $\log \dot{T}$, with a slope of ~ 1.4 . Moir and Jones [12] combined their own measurements of \bar{N}_A versus solidification growth velocity V for two different temperature gradients G (Bridgman solidification and tungsten inert gas weld traversing) with measurements by Pierantoni *et al.* [13] for laser surface melt traversing to show a linear relationship between $\log \bar{N}_A$ and $\log (G\sqrt{V})$ with a slope of unity. Bayraktar *et al.* [14] combined all these results with additional Bridgman measurements to show $\lambda \dot{T}^{1/3} = 250 \mu\text{m} (\text{K/s})^{1/3}$ over the range $0.02 < \dot{T} < 10^6 \text{ K/s}$ where $\lambda = \bar{N}_A^{-1/2}$ is a measure of the primary silicon interparticle spacing. Mandal *et al.* [4] reported mean particle size \bar{D}_A

of primary silicon versus \dot{T} in the range 15 to 31 K/s for Al-17, 22 and 27 wt%Si with 0.1 and 0.2 wt% P additions. Ohmi *et al.* [15, 16] reported \bar{D}_A (but see below) of primary silicon and associated nucleation undercooling ΔT_m for Al-22 and 32 wt%Si for solidification cooling rates in the range 11 to 260 K/s, and showed particle size decreasing linearly with increase in undercooling and increasing with increased cooling rate (results show a reasonable fit with $\Delta T_m = A\dot{T}_{K/s}^n$ with $A = 3.5 \text{ K} (\text{K/s})^{-n}$ and $n = 0.6$). Liang *et al.* [17] measured \bar{N}_A and \bar{D}_A together with formation temperature T_f of primary silicon versus V and G in Bridgman in solidification of Al-18.3 wt%Si for comparison with model predictions for steady state heterogeneous nucleation of the primary silicon from the bulk melt. The experimental results show $N_V \propto \dot{T}^{1.2}$ and that nucleation undercooling increases from ~ 35 to $\sim 52 \text{ K}$ over the range $1 < \dot{T} < 20 \text{ K/s}$, consistent with the model prediction for a nucleation contact angle θ increasing from 26 to 36 deg over the same range of \dot{T} . Most recently Kyffin *et al.* [18] reported the effect of phosphorus inoculation on \bar{N}_A of primary silicon for the range $0.8 < \dot{T} < 16.5 \text{ K/s}$ for comparison with the results of Sulzer [10] for $3 < \dot{T} < 70 \text{ K/s}$, Kaneko *et al.* [11] for $0.02 < \dot{T} < 2 \text{ K/s}$ and Mandal *et al.* [4] for $15 < \dot{T} < 30 \text{ K/s}$.

The present purpose is to investigate the possible generality of the relationships between \bar{N}_V and \dot{T} obtained by Kaneko *et al.* [11], Ohmi *et al.* [15, 16] and Liang *et al.* [17]. The available experimental data are summarised in Table I and plotted in Fig. 1 as $\log \bar{N}_V$ versus $\log \dot{T}$. The results for phosphorus-free samples fall into two groups. Results from Bridgman solidification, TIG weld traversing and laser surface melt

TABLE I Summary of data on \bar{N}_V versus \dot{T} for primary silicon in hypereutectic Al-Si alloys

| Alloy composition wt% | Solidification technique | Range of cooling rate \dot{T} , K/s | Resulting \bar{N}_V mm ⁻³ | \bar{N}_V/\dot{T} , mm ⁻³ (K/s) ⁻¹ | Reference |
|--------------------------------|---------------------------------|---------------------------------------|--|--|--|
| Al-16Si + 0 to 0.17P | Sand and chill casting | 0.56 to 15.3 | – | – | Arnold and Prestley 1961 [9] |
| Al-20Si-1 Cu-1Mg based + 0.16P | Chill casting | 3 to 70 | * 4×10^3 to 2×10^4 | 730 ± 490 | Sulzer 1961 [10] |
| Al-19Si – 0.02P | Cooled in a container | 0.017 to 1.67 | ‡2.5 to 1250 | 390 ± 270 | Kaneko <i>et al.</i> 1978 [11] |
| Al- 17.1, 18.2, 24.8, +30.7Si | TIG and Bridgman | 7.7 to 3690 | †740 to 7×10^5 | 140 ± 80 | Moir and Jones 1991 [12] |
| Al-26Si | Laser surface melt traversing | 1.6×10^4 to 10^6 | ‡ 5×10^6 to 1.8×10^8 | 250 ± 100 | Pierantoni <i>et al.</i> 1992 [13] |
| Al-18.4Si | Bridgman | 0.9 to 15.5 | †64 to 866 | 107 ± 39 | Bayraktar <i>et al.</i> 1992 [14] |
| Al-17, 22, 27Si +0.1 or 0.2 P | Chill casting | 16 to 31 | * 5×10^3 to 5×10^4 | 640 ± 560 | Mandal <i>et al.</i> 1991 [4] |
| Al-22 +32 Si | Crucible cooling, chill casting | 10 to 220 | *14 to 430 | 1.2 ± 0.5 | Ohmi <i>et al.</i> 1991, 1994 [15, 16] |
| Al-18.3Si | Bridgman | 1.0 to 18.9 | †90 to 1260 | 77 ± 21 | Liang <i>et al.</i> 1995 [17] |
| Al-20Si | Bridgman | 0.8 to 16.5 | †150 to 520 | 160 ± 40 | Kyffin <i>et al.</i> 2001 [18] |
| Al-20Si + 0.1P | – | – | †1390 to 9270 | 840 ± 380 | |

Note: * \bar{N}_V calculated from reported mean sectioned diameter \bar{D}_A using $\bar{N}_V = \frac{4}{\pi}(\frac{2}{3})^{1/2} f/\bar{D}_A^3$ with f as volume fraction of primary silicon.

† \bar{N}_V calculated from reported number \bar{N}_A of primary silicon particles per unit area on sections using $\bar{N}_V = (\pi/6f)^{1/2} \bar{N}_A^{3/2}$.

‡ \bar{N}_V calculated by Kaneko *et al.* from \bar{N}_A/\bar{D}_V with $\bar{D}_V = \pi \bar{D}_A/2$, where \bar{D}_V is true mean volume diameter.

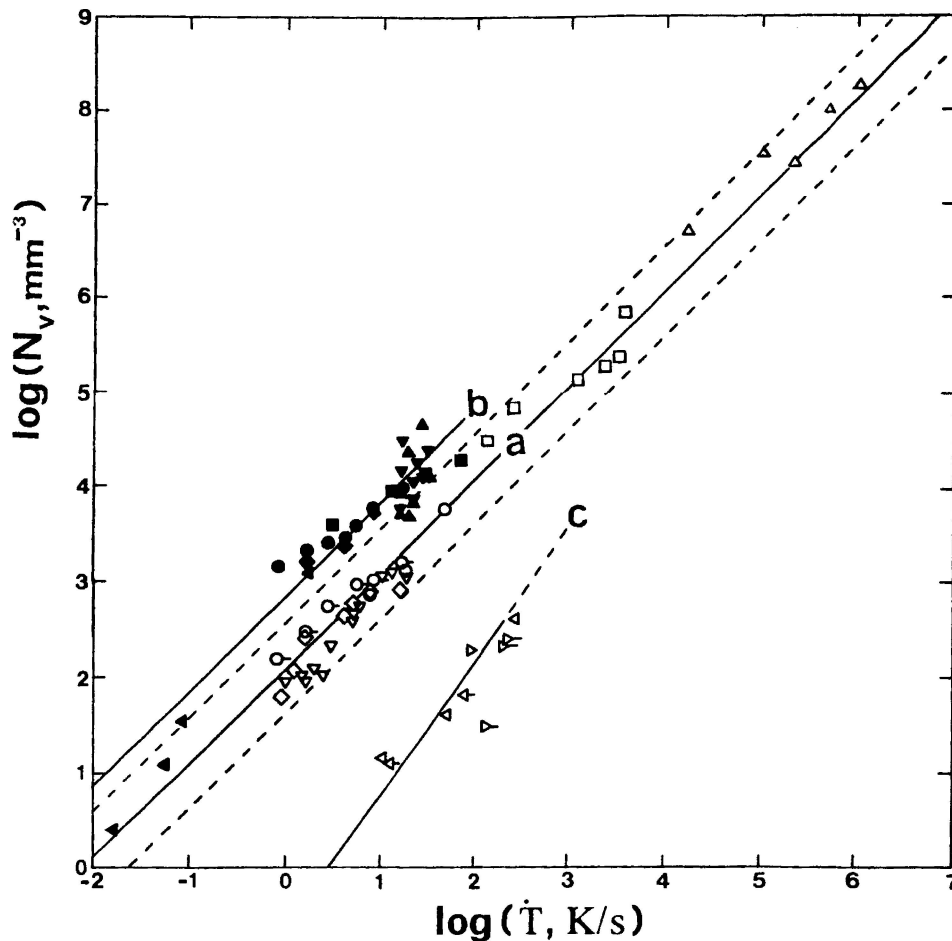


Figure 1 Mean number \bar{N}_V of primary silicon particles per unit volume in hypereutectic Al-Si alloys versus solidification cooling rate \dot{T} . Key: Experimental data ■ Sulzer [10], ▲ Kaneko *et al.* [11], □ Moir and Jones [12] TIG and Bridgman, △ Pierantoni *et al.* [13], ◇ Bayraktar *et al.* [14], ▲ Mandal *et al.* [4] 0.1 and 0.2 wt%P, ◀ Ohmi *et al.* [15, 16] crucible cooling and chill casting ∇ Liang *et al.* [17], ●◆ Kyffin *et al.* [18] 0.0P, 0.1P (Al-Fe-P) and 0.1P (Al-Cu-P). Filled points indicate inoculation with phosphorus. Further details of conditions are in Table I. Line a represents fit of the phosphorus-free data to Equation 1 with $n = 1$ and $A = 130 \text{ mm}^{-3} (\text{K/s})^{-1}$, with factor of 3 scatter band indicated. Line b represents fit of results with phosphorus present to Equation 1 with $n = 1$ and $A = 720 \text{ mm}^{-3} (\text{K/s})^{-1}$. Line c is the prediction of model B of Ohmi *et al.* [19] giving $n = 1.44$ and $A = 0.21 \text{ mm}^{-3} (\text{K/s})^{-1.44}$ in Equation 1

traversing show a good fit (within a factor of 3 in \bar{N}_V) with

$$\bar{N}_V = A\dot{T}^n \quad (1)$$

with $n = 1$ and $A = 130 \text{ mm}^{-3} (\text{K/s})^{-1}$. The results of Ohmi *et al.* [15, 16] for crucible cooling and chill casting, in contrast, show values of \bar{N}_V some two orders of magnitude below the Bridgman and surface melting results. At least part of this discrepancy arises because it now appears that Ohmi *et al.* reported the mean long dimension of their primary silicon particles from sections rather than the mean diameter. Correction for this would move their data points in Fig. 1 closer to the other \bar{N}_V measurements plotted there. Predictions of their nucleation model B [19] give $n = 1.44$ with $A = 0.21 \text{ mm}^{-3} (\text{K/s})^{-1.44}$ in Equation 1 at $\dot{T} < 200 \text{ K/s}$ in good accord with their measurements but exhibits plateaus in \bar{N}_V at $\dot{T} > 200$ to 10^3 K/s depending on superheat. A further significant difference from the Bridgman results of Liang *et al.* was that Liang *et al.*'s associated measured nucleation undercoolings ΔT were relatively larger, e.g. 43 K at 13 K/s compared with 16 K at this cooling rate reported by Ohmi *et al.*, indicative of operation of heterogeneous nucleation at lower undercoolings in their work compared with the Bridgman studies. Fig. 1 also includes results for phosphorus inoculated samples (filled points). Except for the results of Kaneko *et al.* at 0.018 and 0.056 K/s, these lie mostly above the scatter band of the main body of results from phosphorus free samples, showing a fit of \bar{N}_V within a factor of 3 of Equation 1 with $n = 1$ and $A = 720 \text{ mm}^{-3} (\text{K/s})^{-1}$, i.e. a factor of 5.5 higher \bar{N}_V .

In conclusion, collected data for number per unit volume \bar{N}_V of primary silicon particles in hypereutectic Al-Si alloys, derived from measurements of number \bar{N}_A per unit area or mean diameter \bar{D}_A on sections, show a power relation with solidification cooling rate \dot{T} of the form $\bar{N}_V = A\dot{T}^n$, where typically $n \sim 1$ and $A \simeq 130 \text{ mm}^{-3} (\text{K/s})^{-1}$ in the absence of inoculation with phosphorus and $A \simeq 720 \text{ mm}^{-3} (\text{K/s})^{-1}$ in the presence of phosphorus. The significantly lower values of \bar{N}_V from the results of Ohmi *et al.* appear to be associated with measurement of mean long dimension rather than mean diameter of particle sections as well as nucleation at much lower measured undercoolings in their exper-

iments compared with the undercoolings measured in the experiments of Liang *et al.*, which were associated with \bar{N}_V values more typical of the majority of measurements.

Acknowledgements

This work forms part of an MPhil/PhD programme at the University of Sheffield by M F, financed by the Iranian Government

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Received 31 March

and accepted 21 April 2005